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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

INVENTOR:	Ricky S. Amos et al.)	EXAMINER:	Olivia T. Luk
)		
SERIAL NO.:	10/605,261)	ART UNIT:	2812
)		
FILING DATE:	September 18, 2003)	DATE:	7 March 2005
FOR:	PROCESS OPTIONS FOR FORMING SILICIDED METAL GATES FOR ADVANCED CMOS DEVICES			

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Responsive to the Restriction Requirement Office Action mailed February 14, 2005, Applicants provisionally elect the subject matter of Group I, claims 1-6, for examination herein.